



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

February 10, 2026	
IGI Report Number	
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	CUT CORNERED RECTANGULAR MIXED CUT
Measurements	8.34 X 5.92 X 3.99 MM

GRADING RESULTS

Carat Weight	1.91 CARAT
Color Grade	FANCY INTENSE YELLOW
Clarity Grade	VS 1

ADDITIONAL GRADING INFORMATION

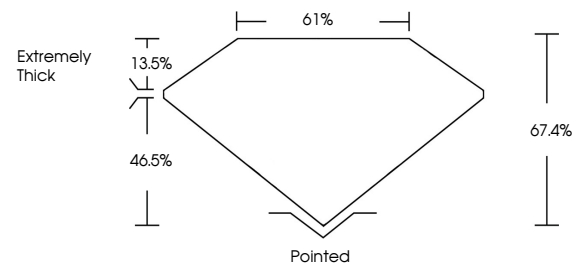
Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.

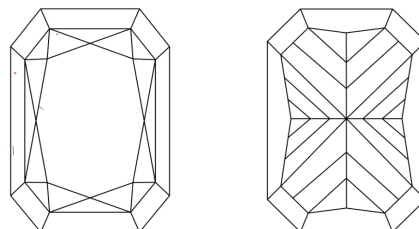
Report verification at igi.org

PROPORTIONS



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

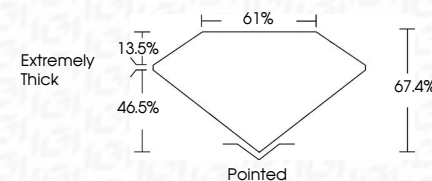
D E F G H I J Faint Very Light Light

CLARITY

FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

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ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	151

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.



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www.igi.org

February 10, 2026	
GJ Report No	
CUT CORNERED RECT	
3.34 X 5.92 X 3.99 MM	FAIR
Carat Weight	
Color Grade	
Clarity Grade	
Depth	
Table	
Girdle	
Culet	
Polish	
Symmetry	
Fluorescence	
Description(s)	

Comments:
This Laboratory Grown Diamond was
created by Chemical Vapor Deposition